

Special Issue

Physical and Chemical Removal of Recalcitrant Pollutants Using Novel Solids: Nanomaterials, Biochar, and Waste-Derived Biomaterials

Message from the Guest Editors

This Special Issue will cover the sustainable physical and chemical removal of recalcitrant pollutants, including topics such as new and innovative nanomaterials, novel biochar, innovative uses of waste-derived biomaterials, circular economy promotion, reduction in fossil-derived plastics and waste-derived biomaterials, simulation, modeling, and techno-economic analyses.

Guest Editors

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Editor-in-Chief

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